

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: L. Chen
Application No.: ~~FILE CONCURRENTLY~~ 09/885232
Filed: ~~CONCURRENTLY~~ 6-20-01
Title: APPARATUS AND METHOD FOR ELECTROLYTICALLY DEPOSITING
COPPER ON A SEMICONDUCTOR WORKPIECE

Attorney Docket No.: SEMT117581
Group Art Unit: -- 1741
Examiner: -- Nicolas

SAH
2A
8-7-01

PRELIMINARY AMENDMENT

Seattle, Washington 98101

June 20, 2001

TO THE COMMISSIONER FOR PATENTS:

In the Specification:

Please amend the specification at page 1, CROSS-REFERENCE TO RELATED APPLICATIONS section, by deleting the first paragraph thereunder reading "Not Applicable" and replace it with the following new paragraph:

This application is a continuation of U.S. Application Serial
No. 09/387,033 filed August 31, 1999, ^{now U.S. Pat. No. 6,290,833,} which is a continuation of
International Application Serial No. PCT/US99/06306 designating the
United States filed March 22, 1999, which is a continuation-in-part of U.S.
Application Serial No. 09/045,245 filed March 20, 1998, ^{now U.S. Pat. No. 6,197,181,} and claims the
benefit of U.S. Provisional Application Serial No. 60/085,675 filed
May 15, 1998, priority from the filing dates of which are hereby claimed
under 35 USC Sections 120 and 119(e), and the disclosures of which are
hereby incorporated in their entirety.

LAW OFFICES OF
CHRISTENSEN O'CONNOR JOHNSON KINDNESS^{PLLC}
1420 Fifth Avenue
Suite 2800
Seattle, Washington 98101
206.682.8100